Energy states in ZnSe-GaAs heterovalent quantum structures

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We investigate the energy states in ZnSe-GaAs heterovalent quantum structures. In the ZnSe-GaAs heterovalent heterostructures, the band offsets are controllable, and therefore different offsets can be put at both sides of the GaAs wells through the control of the growth sequence forming the interfaces, which brings unique characteristics on the heterovalent quantum structures. The characteristic features are examined by the optical-absorption measurement. Dependence of the absorption edge on the offsets and the well width reveals the presence of an electric field; by changing the valence-band offset at one side of the GaAs well from 0.6 to 1.1 eV, while keeping that at the other side constant at 0.6 eV, we observe that the absorption edge energies are shifted toward lower energy and that the degree of the redshift depends on the GaAs well width. These experimental results are well explained by the theoretical calculation of the Poisson and Schrödinger equations. On the other hand, the barrier width dependence exhibits the anomalous behavior that cannot be expressed by the theoretical analyses and is interpreted in terms of the charge transfer within the barrier region.

I. INTRODUCTION

Heterovalent heterostructures such as ZnSe-GaAs and GaAs-Ge possess an attractive characteristic that band offsets between the constituent materials are variable. Different from isovalent heterostructures, the heterovalent heterostructures include interface electronic dipoles owing to inevitably formed donor and acceptor bonds, which play a crucial role in determining the band offsets. The strength and direction of the dipoles depend sensitively on the microscopic interface atomic configuration and, thus, so do the band offsets. Variations of the band offsets for ZnSe-GaAs, Ge-GaAs, and Si-GaP have been theoretically predicted to be as large as 1.0, 0.6, 0.8 eV, respectively.

Experimentally, the effect of the interfacial properties on the tunability of the band offsets has already been investigated for several prototypical lattice matched and theoretically well-understood heterostructures. ZnSe-GaAs is one of the most suitable material combinations for the study of heterovalency because the lattice mismatch is as small as 0.27% at room temperature (RT) and modification of the properties induced by the lattice mismatch is not significant. We have recently demonstrated the controllability of the band offsets in ZnSe-on-GaAs(001) [ZnSe/GaAs(001)] (Refs. 5 and 9) and GaAs-on-ZnSe(001) [GaAs/ZnSe(001)] (Ref. 6) heterostructures; the valence-band offsets could be tuned from 0.6 to 1.1 eV by manipulating the interfacial atomic geometry through precise control of the flow sequence of the source precursors at the interfaces. These studies opened a way to fabricate various multilayered structures from the ZnSe-GaAs system. For example, the offset divided into both the valence and the conduction bands may lead to formation of quantum structures, while, if the offset is put mainly on either the valence or the conduction band, double heterojunction bipolar or phototransistors with the high injection efficiency can be realized.

In this study, we fabricate the ZnSe-GaAs heterovalent quantum structures in which the band offsets on both sides of the GaAs wells are independently designed and characterize their properties chiefly originating from heterovalency. The fabricated structures are mostly multiple quantum wells (MQW’s) and partially superlattices. When the band offsets at both interfaces are different, the quantum structures should contain an electric field. Since the intensity of the electric field is changeable via control of the band offsets, the properties of the quantum structures are variable as well. So far, the effects of electric fields on the nature of the eigenstates have been investigated using the conventional isovalent quantum structures such as a GaAs-AlGaAs system. If each well in a quantum structure is sufficiently isolated, which is the situation in a QW structure, the energy gaps will be shifted toward lower energy by the electric field. In the case of superlattices, the electric field causes Wannier-Stark localization. In these studies, however, the electric field was applied externally by, for example, pin and nin structures. On the other hand, a characteristic of the heterovalent quantum structures is that a new parameter of the band offset for designing the electronic properties enables the electric field to be included internally. Furthermore, since the tunability of the offsets depends on the interfacial dipoles being a function of the interfacial charge distribution, the structures that rearrange the charge distribution may alter the electronic properties. In this paper, we investigate dependence of the energy states in the ZnSe-GaAs heterovalent quantum structures, which include the intrinsic electric field, on the offsets, the well width, and the barrier width to provide an insight into their basic properties. The experimental results obtained by optical-absorption measurement at 22 K are compared with the results of the theoretical analyses using the Poisson and Schrödinger equations.

II. THEORETICAL BACKGROUND

The electronic properties of a quantum structure with an electric field are described by the one-dimensional Poisson and Schrödinger equations. Strictly, these equations should...
be solved self-consistently; though for simplicity, the following approximation has been made in this study. The quantum confinement effect was not considered in the Poisson equation, and the carrier concentrations were written in classical formulations using the Ehrenberg approximation. Within the limits of this classical approximation, the potential-energy profiles are uniquely determined only by the Poisson equation. Therefore, eigenstates are, then, calculated by solving the Schrödinger equation, where carriers experience the potential profile derived from the Poisson equation. Although this procedure is not self-consistent and may degrade the quantitative accuracy, the included error does not seem to be serious due to the following reasons. If the well width is thick, the classical density of states well approximates that with the quantum effect. The thin well, on the other hand, induces the substantial difference in the density of states, although the electric field, in turn, does not influence eigenstates remarkably. Therefore, the electronic properties of the heterovalent quantum structures can be outlined by the procedure adopted here with relative easiness.

A. Potential-energy profiles

Since the samples fabricated in this study are multilayered quantum structures, the Poisson equation is solved with the periodic boundary conditions. Figure 1 shows some of the calculated potential profiles of the MQW’s. The dimensions of the GaAs wells and the ZnSe barriers are 100 and 110 Å, respectively. The pairs of the valence-band offsets at both sides of the GaAs wells are (a) 0.6/0.6, (b) 0.6/0.9, and (c) 0.6/1.1 eV. These structural and physical parameters were chosen, referring to the actually fabricated structures (cf. Sec. III). Here, ZnSe is assumed to be n type with donor concentration of $1 \times 10^{11}$ cm$^{-3}$, while GaAs is p type with $5 \times 10^{17}$ cm$^{-3}$. These quantities are the experimental results obtained from Hall-effect measurements of thick layers but are not essential as will be shown later. It is obvious from Fig. 1 that the electric field, which corresponds to the inclination of the potential profile, becomes stronger by the increase of the difference of the valence-band offsets and that its intensity is approximately uniform in either the ZnSe or the GaAs region.

Based on Fig. 1, the average electric fields in the well and the barrier regions were estimated on the assumption that the electric field was uniform in each region. The results are shown in Fig. 2, where the valence-band offset at one side of GaAs is 0.6 eV and that at the other side is a variable designated at the horizontal axis. Variation due to the well width is also compared. The intensities of the electric fields are almost proportional to the difference of the valence-band offsets and are stronger in the MQW’s with the narrower wells.

As is well known, impurity concentration often influences the potential profile of semiconductor heterojunctions. Surprisingly, however, it was found that the potential profiles of the heterovalent quantum structures hardly depended on the impurity concentration and that those were mainly determined by the difference of the valence-band offsets at both sides of the GaAs wells. For example, when the valence-band offsets at both interfaces are 0.6 and 1.1 eV, difference of the acceptor concentrations in GaAs of $1 \times 10^{14}$ and $5 \times 10^{17}$ cm$^{-3}$ resulted in only a few percent of variation of the electric fields, that is, 195 kV/cm and 184 kV/cm in GaAs, respectively. Furthermore, p- and n-GaAs with the same impurity concentration of $5 \times 10^{17}$ cm$^{-3}$ exhibited the almost identical potential profiles; electric fields in GaAs were 184 kV/cm for p-GaAs, while 183 kV/cm for n-GaAs. The similar tendency was observed by changing the impurity concentration in ZnSe. The reason for this independence on the impurity concentration is that the potential inclination due to the difference of the valence-band offsets is remarkably greater than that induced by donor and acceptor impurities and determines the potential profiles predominantly.

B. Energy eigenstates

Under the presence of the electric field revealed by the Poisson equation, the Schrödinger equation was solved by the variational method$^{13}$ to estimate the energy eigenstates. A single QW with ZnSe barriers of infinite width was used as a model for the calculation. This approximation is valid for most of the present quantum structures, because their barrier width is typically about 110 Å and the penetration of the calculated wave function into the ZnSe barrier regions...
Examples of the calculated energy gaps are shown in Fig. 3, where the dimension of the GaAs well is a parameter and that of the ZnSe barrier used for the calculation of the potential profiles is 110 Å.

was totally within about 100 Å. Namely, these are MQW’s, in which the wave function in each well is thoroughly isolated and hardly interacts with one another. The used variational wave functions are basically the same with those in Ref. 13, though were modified to satisfy the boundary conditions of \( \psi_{\text{GaAs}} = \psi_{\text{ZnSe}} \) and \( m^*_\text{GaAs}^{-1}(d\psi_{\text{GaAs}}/dz) = m^*_\text{ZnSe}^{-1}(d\psi_{\text{ZnSe}}/dz) \) at the interfaces, where \( \psi \) and \( m^* \) denote the wave functions and the effective masses for the indicated material. The energy gap was estimated from the eigenstates determined by the Schrödinger equation, assuming the energy band gap of GaAs at 20 K as 1.521 eV.

On the other hand, \( F_b \) in the range from −500 to 500 kV/cm with zero \( F_w \) and the pair of the valence-band offsets of 0.6/1.1 eV resulted in a trivial change of the energy gap in the order of sub meV. Although this variation due to \( F_b \) is enlarged by the increase of \( F_w \), its order is still meV even with \( F_w = 500 \) kV/cm. The reason for the enhancement of the redshift by greater \( F_w \) is that the wave functions are spatially shifted toward the well barriers by \( F_w \) to be more sensitive to the electric field in the barriers, i.e., \( F_b \).

As for the effect of the band offset on the energy gap, the calculation was carried out, keeping the valence-band offset at one side of the GaAs well at 0.6 eV and changing that at the other side between 0.6 and 1.1 eV. \( F_w \) was assumed to be 0 V/cm. The degree of the energy shift owing to control of the band offsets depends on \( F_w \). The larger \( F_w \) causes the greater energy shift, although even under \( F_w = 500 \) kV/cm, the shift due to the change of the valence-band offsets from 0.6 to 1.1 eV was estimated to be only about 15 meV. From the above discussions, it can be concluded that the offset itself is not important and that the electric field in the GaAs wells as a function of the offset plays a principal role in determining the energy gap.

In Secs. II A and II B, the existence of strain, which modifies the energy bands, has been neglected. Here, the validity of this assumption is proved. Since the ZnSe-GaAs quantum heterostructures are grown on the GaAs substrates in this study, only the ZnSe layers are strained to achieve pseudomorphic growth as verified in Sec. III B. The lattice parameter of ZnSe is 5.668 Å, while that of GaAs is 5.653 Å at RT, and thus the strain in ZnSe is compressive. The effect of the compressive strain on the energy band of ZnSe is estimated with the model-solid theory proposed by Van de Walle et al.,14,15 The used physical parameters are the same with those in Ref. 15. As a result, it was found that the compressive strain in ZnSe makes the band offsets larger by 2 meV for heavy holes, by 10 meV for light holes, and by 9 meV for electrons. Using these values, the Poisson equation

\[
\frac{\partial^2 \psi}{\partial z^2} + \left( E - \frac{\hbar^2}{2m^*} \right) \psi = 0
\]

was solved for the redshift of the energy gap, that is, \( F_w \) from 0 to −500 kV/cm brought the energy gaps from 1.559 to 1.287 eV, respectively. Under the positive \( F_w \), both electron and hole wave functions are pushed to the interfaces with the smaller band offsets and penetration into the barrier regions becomes pronounced, compared with that under the positive \( F_w \). This causes the quantitative difference of the energy gaps of 1.362 and 1.287 eV under ±500 kV/cm. However, an important result of this calculation is that \( F_w \) can potentially bring about the variation of the energy gap in hundreds meV.

In this study, the periodic potential profile like Fig. 1 is considered as a first trial. However, actually, the band offset at each interface in a multilayered structure can be designed independently, and besides, the well and barrier widths that influence the intensity of the electric fields are variable as well. Therefore, various potential profiles can be realized. In this sense, it is crucially important to give a guiding principle for designing the electronic properties of the heterovalent quantum structure. Here, we identify which is most responsible for the redshift, the electric field in the GaAs wells (\( F_w \)), that in the ZnSe barriers (\( F_b \)), or the band offsets, by examining the contribution of each factor to the energy gap separately. The potential profiles for this calculation were determined irrespectively of the result of the Poisson equation, and the GaAs well width was kept constant at 100 Å.

It was found that the energy gap shifted from 1.561 to 1.362 eV by the presence of \( F_w \) from 0 to 500 kV/cm, respectively, where \( F_b \) was zero and the pair of the valence-band offsets was 0.6/1.1 eV. The sign of positive \( F_w \) means that its vector is pointing toward the interface with the valence-band offset of 1.1 eV. The redshift was also observed by \( F_w \) in the opposite direction, that is, \( F_w \) from 0 to −500 kV/cm brought the energy gaps from 1.559 to 1.287 eV, respectively. Under the negative \( F_w \), both electron and hole wave functions are pushed to the interfaces with the smaller band offsets and penetration into the barrier regions becomes pronounced, compared with that under the positive \( F_w \). This causes the quantitative difference of the energy gaps of 1.362 and 1.287 eV under ±500 kV/cm. However, an important result of this calculation is that \( F_w \) can potentially bring about the variation of the energy gap in hundreds meV.

FIG. 3. Calculated energy gaps as a function of the valence-band offset. The dimension of the GaAs well is a parameter and that of the ZnSe barrier used for the calculation of the potential profiles is 110 Å.
was solved again. However, there was no difference in the electrostatic potentials with and without strain. In other words, the change provided in the potential-energy profiles by the strain was only band offsets, and the electric fields in ZnSe and GaAs remain unchanged. This is quite reasonable because, as was mentioned in the previous section, the potential profile is governed chiefly by the difference of the valence-band offsets at both interfaces, and the modification of the energy band owing to the compressive strain does not alter the difference of the offsets. Then, the Schrödinger equation was solved using the newly calculated potential-energy profile. As is easily deduced, since the electric field in GaAs, which was revealed to be essential to determine energy eigenvalues, is unchanged by the strain, the energy shift seems to be considerably small, and indeed, it was estimated for MQW with 100 Å GaAs to be in the order of meV or less. Compared with the variation of the energy gap shown in Fig. 3, this quantity is negligible, which validates the assumption made for the present calculation. We will also neglect the influence of strain on the experimental data.

III. EXPERIMENTAL RESULTS AND DISCUSSION

A. Sample preparation

The ZnSe-GaAs quantum structures were fabricated on GaAs(001) substrates by metal-organic vapor phase epitaxy (MOVPE). The source precursors for GaAs and ZnSe were triethylgallium (TEGa) and tertiarybutylarsine (TBAs), and diethylzinc (DEZn) and dimethylselenium (DMSe), respectively. The sample structure is schematically shown in Fig. 4. Growth of the samples was initiated by a GaAs buffer layer 1500-Å thick at 700 °C. To obtain an atomically flat surface, post-growth annealing was conducted at 700 °C for 10 min. Next a 500-Å-thick ZnSe region was grown at 450 °C primarily to act as an etch stop layer for substrate removal. Finally, a ZnSe-GaAs quantum structure was grown at 450 °C. The period of the quantum structure was designed so as to make the total thickness of the GaAs wells 600–800 Å. The detailed growth conditions are found in Refs. 5 and 6, and references therein. The valence-band offsets in both ZnSe/GaAs and GaAs/ZnSe heterostructures are controllable. In this study, however, to simplify the discussion, the former was kept constant at 0.6 eV for all samples, while the latter was changed between 0.6 and 1.1 eV. For this control of the band offset, the interval duration between the ZnSe and GaAs growth, during which only hydrogen was supplied for purging the ZnSe source precursors, was set at 5 s, and the GaAs growth was initiated after the exposure of ZnSe to TBAs for 2–20 s (see Ref. 6 for more details). The influence of this artificial control of the band offsets on the electronic states is assessed by optical-absorption measurement at 22 K.

B. Structural properties

In order to extract differences of the optical properties due to the interface engineering, it is important to clarify the structural properties, because the structural properties may also contribute to the modification of the optical properties of the quantum structures. For this purpose, the surface morphology and the crystallinity were investigated by means of atomic force microscopy (AFM) and x-ray diffraction (XRD), respectively.

The AFM observation was carried out in air immediately after the growth. There is no evident difference associated with the interface control, and the surfaces for all samples exhibited atomically flat terraces and monomolecular steps (2.8 Å in height) as shown in Fig. 5. This result suggests that, regardless of the manner to prepare the interfaces, the growths of both ZnSe/GaAs and GaAs/ZnSe are in the two-dimensional growth mode under the conditions employed here and that the interfaces are abrupt.

The XRD patterns were taken in the vicinity of the GaAs 004 diffraction, using Cu Kα1 (1.5405 Å) radiation as an x-ray source. Figure 6 shows an example of the XRD profiles, in which both experimental and simulated profiles are illustrated. The sample, in this particular case, is the 8 periods MQW with the expected dimensions of 110 Å for ZnSe and 100 Å for GaAs. Comparison between the experimental result and the simulation based on the dynamical diffraction theory indicates that those are 107 and 99 Å, which are very close to the designed parameters. In the experimental profile, in addition to a fundamental peak (n = 0), well-defined satellite peaks labeled n = ±1 are clearly detected. The peak...
intensity ratios between the satellite and the fundamental
peaks and the full width at the half maximum (FWHM)
agree quite well with those derived from the dynamical
simulation, indicating the high crystalline quality, high peri-
odicity, and high interface abruptness in the ZnSe-GaAs
quantum structure. The ZnSe etch stop layer 500-Å thick
contributes to the increase of the diffraction intensity be-
tween 21000 and 2500 arcsec, for which the experiment
again does agree with the calculation. In the simulation,
ZnSe was assumed to be deformed so as to maintain coher-
ent growth, and the correspondence with the experimental
result supports this assumption. The entire region of the
quantum structure is grown coherently on the GaAs substrate
with few dislocations. It should be emphasized that fairly
good agreement between experiment and simulation was
confirmed for all samples, which allows us to interpret the
optical properties without caring about structural imperfec-
tions.

C. Optical-absorption properties

We will move to the discussion on the optical-absorption
measurement. For the absorption measurement, the substrate of the samples was removed by a selective NaOH(1N):
H2O2 = 1:1 (in volume) etching solution at RT. The light
from a halogen lamp was irradiated to the samples, and the
transmitted light was detected using a cooled charge coupled
device (CCD) and a 50-cm monochromator. The intensity of the irradiated light was made as weak as possible so as to
avoid unexpected modification of the band alignment due to
the photogenerated carriers. Under the present experimental
setup, no luminescence was observed, and therefore, the
detected signals reflect only the absorption properties.

Figure 7 shows a typical 22 K absorption spectrum of the
ZnSe-GaAs heterovalent quantum structure, which consists
of eight periods of 110 Å ZnSe and 100 Å GaAs. The
valence-band offsets at ZnSe/GaAs and GaAs/ZnSe are designed to be 0.6 and 1.1 eV, respectively. Since excitonic absorption peaks were not detected, the following discussion has been done based on the absorption edge, which was defined as the en-
ergy determined by extrapolation of linear dependence of the
square of the absorbance on irradiated photon energy into
zero absorbance. It must be noted that the absorption edge energy (Eabs) is generally lower than the energy gap (Eg)
due to absorption by impurities and/or excitons, that is,

\[ E_{\text{abs}} = E_g - \Delta E_{\text{abs}}, \]

where \( \Delta E_{\text{abs}} \) indicates the variation caused by the impurity
and/or exciton absorption. In this study, however, the contri-

FIG. 6. An example of the XRD profiles of the ZnSe-GaAs
quantum structures. The agreement between the experimental result
and the theoretically calculated profile indicates the high degree of the structural perfection.

FIG. 7. Typical absorption spectrum of the ZnSe-GaAs heterovalent quantum structure measured at 22 K. The sample is the eight periods MQW consisting of 110 Å ZnSe and 100 Å GaAs. The valence-band offsets at ZnSe/GaAs and GaAs/ZnSe are 0.6 and 1.1 eV, respectively.

FIG. 8. The absorption edge energies of the MQW’s with different pairs of the valence-band offsets at both sides of the GaAs wells. The valence band offset at the ZnSe/GaAs interfaces is constant at 0.6 eV. Thickness of ZnSe is 110 Å for all samples in this figure. The broken lines indicate the theoretically determined absorption energies (E_{\text{abs}}), which were evaluated by subtracting the exciton binding energies from the energy gaps (E_g).
bution from impurities to $\Delta E_{\text{abs}}$ is considered to be negligible. This is because the absorption edge energy of GaAs 1150-Å thick grown on ZnSe/GaAs was estimated to be 1.518 eV, and the energy difference of 3 meV between the estimated value (1.518 eV) and the energy band gap of GaAs at 20 K (1.521 eV) is close to the exciton binding energy of bulk GaAs ($\sim$5 meV). In the following, $\Delta E_{\text{abs}}$ is determined by referring to the exciton binding energy calculated in Ref. 16.

1. Band offset dependence

The absorption edge energies of the MQW’s with different pairs of the valence-band offsets at both sides of the GaAs wells are compared in Fig. 8. The ZnSe barrier thickness was 110 Å for the samples in Fig. 8. The valence-band offset at the ZnSe/GaAs interface is 0.6 eV as stated before, and that at the GaAs/ZnSe interfaces is a variable indicated at the horizontal axis. Accordingly, for example, the valence-band offset of 0.6 eV in the figure means the flatband condition. The result with 220 Å GaAs and the valence-band offset of 1.1 eV may be less reliable. Since the electron and hole wave functions are remarkably separated under the structural and physical parameters for this sample, the absorption is suppressed, and consequently, the signal-to-noise ratio in the experiment gets worse.

It is explicitly seen in Fig. 8 that the MQW’s with the larger valence-band offset, which corresponds to the larger difference of the valence-band offsets at both sides of GaAs, exhibit the lower absorption energy and that the redshift becomes more conspicuous in the MQW’s with the wider wells. The broken lines in the figure indicate the absorption energies ($E_{\text{abs}}$) calculated from Eq. (1), that is, by subtracting $\Delta E_{\text{abs}}$ from energy gaps ($E_g$) shown in Fig. 3. As $\Delta E_{\text{abs}}$ in Eq. (1), which is equal to the exciton binding energy, 19, 15, and 11 meV were used for MQW’s with the well width of 70, 100, and 220 Å, respectively, according to the calculated results in Ref. 16. It is worth noting that those exciton binding energies are larger than those in the GaAs-AlAs system owing to the large difference in the dielectric constants between GaAs and ZnSe. Strictly, the exciton binding energy depends on the intensity of the electric field; though, here, it was assumed to be constant at the value without electric fields as a first trial. The reasonable agreement between the experimental results and the theoretical calculations indicates that the electronic properties in the heterovalent MQW’s are well described by the potential profiles shown in Fig. 1 and by the energy eigenvalues determined by the profiles. Moreover, it can be concluded that the modification of the exciton binding energy due to the presence of the electric field is within the present experimental resolution. It is interesting to note that the results obtained here prove the capability of controlling the electronic properties of heterovalent MQW’s through the control of the band offsets, which differs considerably from isovalent systems.

2. Well width dependence

The quantum confinement effect was examined by the well width dependence of the absorption edges. The samples used for this experiment possess the ZnSe barriers 110-Å thick. Two series of the samples, that is, with and without difference between the band offsets at both sides of GaAs, were investigated. For the former, the valence-band offsets at the ZnSe/GaAs and the GaAs/ZnSe interfaces are 0.6 and 1.1 eV, respectively, which yields the internal electric field. In the latter case, both valence-band offsets are 0.6 eV, and thus, there is no electric field.

The results are shown in Fig. 9. The broken lines are the theoretically calculated absorption energies with the consideration of the exciton binding energy. Similar to Fig. 8, the fairly good agreement between the experiment and the calculation was again attained, indicating the achievement of the quantum confinement. Furthermore, it is clearly observed from either the experiment or the calculation that as the well width is widened, the variation of the energy gap due to the electric field becomes pronounced, as was already pointed out in Sec. II B. The results here support the conclusion in the previous section that the electronic properties of heterovalent MQW’s are controllable by the interface control.

3. Barrier width dependence

Finally, we describe the barrier width dependence. As decreasing the barrier width, quantum structures are generally converted from MQW’s to superlattices in which the wave functions in wells interact with each other to form minibands. In the conventional isovalent quantum structures, formation of the minibands due to the conversion from MQW’s to superlattices appears in the absorption properties as the lowered absorption edge. Our interest is what is observed in the heterovalent quantum structures by changing the barrier width. In order to elicit the difference between the isovalent and heterovalent quantum structures, different valence-band offsets were set at the ZnSe/GaAs and the GaAs/ZnSe interfaces as 0.6 and 1.1 eV, respectively. The dimension of the GaAs wells was 100 Å.

Before showing the experimental details, the theoretical analyses are briefly performed. First, the miniband structures were calculated by the Kronig-Penny model assuming the quantum structures without electric fields. It was demonstrated that the first miniband for electrons was formed with
The barriers less than 70-Å thick and that its width at the barrier width of 30 Å was 1.5 meV. Since the presence of an electric field localizes the carriers and prevents the formation of the minibands, the result above suggests that the calculation process of the Schrödinger equation employed in this study does not involve a serious error for the multiple quantum structures with barriers thicker than 70 Å. For superlattices with barriers thinner than 70 Å, the quantitative accuracy is surely degraded, although it is still possible to extract the trend of the energy states against the barrier width by the same technique. This is because the variation of the energy levels due to the conversion into superlattices, that is, due to the formation of the minibands, is relatively small as was estimated to be 1.5 meV for the barriers 30-Å thick. Consequently, it was found that as the barrier width was reduced from 110 to 30 Å, the electric field in the GaAs regions became stronger and the energy gap shifted monotonously from 1.518 to 1.444 eV. Namely, the theoretical prediction is that redshift will be observed also in heterovalent systems by reducing the barrier width, though that is predominantly caused by the internal electric field, differing from isovalent systems. The redshift due to formation of the minibands will be too small to be observed.

Experimentally, the absorption edge energy behaves contrary to the theoretical prediction as shown in Fig. 10. As the barrier width decreases from 110 Å, it is once shifted to higher energy, and then shows the redshift below 50 Å. Regarding the blueshift, it cannot be interpreted by the theoretical analyses so far performed in this study, and therefore, another factor must be considered. According to Figs. 2 and 3, the blueshift means that the difference of the valence-band offsets at both sides of the GaAs wells gets smaller as a whole, which makes the difference of the valence-band offsets small. Consequently, it was found that as the barrier width was reduced from 110 to 30 Å, the electric field in the GaAs regions became stronger and the energy gap shifted monotonously from 1.518 to 1.444 eV. Namely, the theoretical prediction is that redshift will be observed also in heterovalent systems by reducing the barrier width, though that is predominantly caused by the internal electric field, differing from isovalent systems. The redshift due to formation of the minibands will be too small to be observed.

Concerning the redshift below 50 Å, the theoretical analyses stated previously in this section suggest that this is probably due to the electric field because the amount of the observed redshift is 50–60 meV, which is much greater than the calculated width of the first miniband. The reason why the effect of the electric field appears explicitly in the quantum structures with the barriers thinner than 50 Å is considered as follows. The final charge distribution is decided not only by the ZnSe thickness but also by other factors such as the charges at the GaAs side of the interfaces and the donor and acceptor bonds at the interfaces. In Fig. 10, the charge transfer due to the variation of the ZnSe thickness will be completed at about 50 Å, and the electric field remained after...
the charge transfer is strengthened by thinning the barrier width and causes the redshift.

Although the similar charge transfer must take place in the GaAs wells by reducing the GaAs well width, observation of this phenomenon will be difficult because the influence of the electric field on the absorption energy is originally not so remarkable in the narrow wells as shown in Fig. 9. The barrier width dependence shown here is one of the unique characteristics of the heterovalent quantum structures, which is never observed with the conventional isovalent systems.

IV. CONCLUSIONS

ZnSe-GaAs(001) heterovalent quantum structures were fabricated, and their optical properties were assessed by the absorption measurement at 22 K. Dependence of the absorption edge energy on the offsets, the well width, and the barrier width was investigated. The absorption edges were shifted toward lower energy by enlarging the difference of the valence-band offsets at both sides of the GaAs wells. This was an indication of the presence of the internal electric field. The well width dependence also provided evidence of the presence of the electric field. The theoretical calculation of the Poisson and Schrödinger equations well explained these experimental results. In contrast, the barrier width dependence exhibited the anomalous behavior and could not be expressed by the theoretical analyses. This unique characteristic was interpreted in terms of the charge transfer within the barrier region.

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In this paper, a (material A)-on-(material B) structure is denoted as A/B and a multilayered structure consisting of (material A) and (material B) as A-B.

17. The overlap integral between electron and hole wave functions was calculated to be about 10% of that without electric field.